## Vincent P Labella

List of Publications by Year in descending order

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		1307594	1199594	
17	135	7	12	
papers	citations	h-index	g-index	
17	17	17	178	
all docs	docs citations	times ranked	citing authors	

#	Article	IF	CITATIONS
1	Determination of the energetic resolution of Schottky barrier visualization via interface band structure and parallel momentum conservation. AIP Advances, 2021, 11, .	1.3	1
2	Visualizing metal/HfO2/SiO2/Si(001) interface electrostatic barrier heights with ballistic hole emission microscopy. Journal of Applied Physics, 2019, 126, 195302.	2.5	1
3	Nanoscale Schottky barrier visualization utilizing computational modeling and ballistic electron emission microscopy. Journal of Applied Physics, 2018, 123, .	2.5	3
4	Detection of silicide formation in nanoscale visualization of interface electrostatics. Applied Physics Letters, 2017, 110, 141606.	3.3	6
5	Nanoscale Schottky barrier mapping of thermally evaporated and sputter deposited W/Si(001) diodes using ballistic electron emission microscopy. Journal of Vacuum Science and Technology B:Nanotechnology and Microelectronics, 2016, 34, .	1.2	6
6	Relating spatially resolved maps of the Schottky barrier height to metal/semiconductor interface composition. Journal of Applied Physics, $2016$ , $119$ , .	2.5	7
7	Pulsed-N2 assisted growth of 5-20 nm thick <i><math>\hat{l}^2</math></i> +W films. AIP Advances, 2015, 5, .	1.3	4
8	Time dependent changes in Schottky barrier mapping of the W/Si(001) interface utilizing ballistic electron emission microscopy. Journal of Applied Physics, 2015, $117$ , .	2.5	12
9	Microstructure fabrication process induced modulations in CVD graphene. AIP Advances, 2014, 4, 127143.	1.3	3
10	Nanoscale mapping of the W/Si(001) Schottky barrier. Journal of Applied Physics, 2014, 116, 023705.	2.5	9
11	Fabrication of 5-20 nm thick $\langle i \rangle \hat{l}^2 \langle  i \rangle$ -W films. AIP Advances, 2014, 4, .	1.3	21
12	Characterization of metal oxide layers grown on CVD graphene. Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films, 2013, 31, .	2.1	7
13	Schottky barrier height measurements of Cu/Si(001), Ag/Si(001), and Au/Si(001) interfaces utilizing ballistic electron emission microscopy and ballistic hole emission microscopy. AIP Advances, 2013, 3, .	1.3	31
14	Signatures of the semiconductor crystallographic orientation on the charge transport across non-epitaxial diodes. Applied Physics Letters, 2012, 100, .	3.3	8
15	Schottky barrier and attenuation length for hot hole injection in nonepitaxial Au on p-type GaAs. Journal of Vacuum Science and Technology B:Nanotechnology and Microelectronics, 2012, 30, 04E110.	1.2	3
16	Fabrication of an electrical spin transport device utilizing a diazonium salt/hafnium oxide interface layer on epitaxial graphene grown on 6 H-SiC(0001). Journal of Vacuum Science and Technology B:Nanotechnology and Microelectronics, 2012, 30, 04E109.	1.2	5
17	Temperature dependent spin precession measurements in trilayer graphene utilizing co/graphene contacts. Journal of Vacuum Science and Technology B:Nanotechnology and Microelectronics, 2012, 30, 03D115.	1.2	8